2022

(Held in 2023)

PHYSICS

(Theory Paper)

Paper Code: PHY-304

(Advanced Condensed Matter Physics - I)

Full Marks - 80

Pass Marks - 32

Time - Three hours

The figures in the margin indicate full marks for the questions.

- 1. Answer all the following questions: $1 \times 5 = 5$
 - (a) The metal-n type semiconductor, where the work function of metal is greater than the semiconductor is a
 - (i) Rectifying contact
 - (ii) Ohmic contact
 - (iii) Near Ohmic contact
 - (iv) None of the above

Turn over

- (b) Under reverse bias
 - (i) Depletion width of a p-n junction reduces
 - (ii) Depletion width of a p-n junction increases
 - (iii) Built-in potential decreases
 - (iv) None of the above
- (c) Electroplating technique is suitable for
 - (i) Coating with considerable thickness
 - (ii) Coating without use of electric current
 - (iii) Making conduction films of gold or
 - (iv) Making dielectric films
- (d) Advantage of sputtering is
 - (i) Good coating and step coverage
 - (ii) Less adhesion
 - (iii) Targets wear out uniformly
 - (iv) Preserves stoichiometry of multi-component compounds
- (e) Which are the main parameters governing
 - (i) Substrate temperature and deposition rate
 - (ii) Particle density and source temperature
 - (iii) Particle mass and energy
 - (iv) Particle mass and deposition rate.
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- 2. Answer the following questions: $2 \times 5 = 10$
 - (a) Why DC sputtering does not work for an insulating film? Explain how do you overcome this?
 - (b) What do you mean by size effect? Mention the two fundamental scattering mechanisms of electrons in thin films.
 - (c) What are the types of capacitance associated with a p-n junction? Explain.
 - (d) Discuss the operating principle of photodiode and LEDs.
 - (e) What are the important characteristics of Quantum confinement?
- Answer any five of the following questions:

5×5=25

- (a) Discuss the sol-gel process for the preparation of nanomaterial with the help of block diagram. Write its drawbacks. 4+1=5
- (b) Explain the term Nucleation. What are Homogenous and Heterogeneous Nucleations of thin films? Discuss the various pre nucleation theories with the help of diagram. 1+1+3=5
- (c) What do you mean by Quantum Hall Effect? Explain the phenomenon of integral and fractional quantum Hall Effect. 1+4=5

(d) Obtain the diffusion and drift current density due to electrons and holes in a semiconductor.

(e) Deduce the effective band gap of a quantum dot. How the band gap of a quantum dot is different from its parent bulk material?

4+1=5

- (f) Obtain the density of states of twodimensional systems.
- (g) An abrupt Si p-n junction with cross-section area $A=0.001~\rm cm^{-2}$ has $N_a=10^{15}~\rm cm^{-3}$ on one side and $N_d=10^{17}~\rm cm^{-3}$ on the other. Calculate the following:
 - (i) Contact potential v₀ at room temperature
 - (ii) Space-charge width at zero bias voltage (Consider for silicon, $\epsilon_r = 12$, $n_i = 1.5 \times 10^{10}$ cm⁻³ and $\epsilon_0 = 8.85 \times 10^{-12}$ F/m).
- 4. Answer any four of the following questions: $10\times4=40$
 - (a) (i) Explain the working principle of resistive thermal evaporation with the help of schematic diagram. Discuss the advantages and disadvantages of this technique.

 3+2=5

- (ii) Explain the three different growth modes of thin films. Which one of the mode is favorable for smooth, continuous growth of thin film? Explain. 3+2=5
- (b) (i) Write the statement of Beer's law.

 Discuss the Beer's law for a material having absorption coefficient α and thickness 1 and hence deduce the relation

 1+4=5

$$T = (1 - R)^2 \exp(-\alpha l)$$

(The symbols have their usual meanings.)

- (ii) Explain the term interband luminescence. Discuss the luminescence for direct band gap and indirect band gap semiconductors with the help of schematic band diagram.

 1+4=5
- (c) (i) Explain the term Phonon. Discuss the Normal and Umklapp process of phonon scattering using relevant momentum vector diagram.

 1+4=5
 - (ii) Discuss the inelastic scattering of photons by phonons and hence obtain the relation:

$$\Omega = \frac{2\upsilon\omega\mu\sin\phi}{C}$$

where the symbols have usual meanings.

- (d) Obtain the built-in potential of a p-n junction and deduce the expression for space charge region.

 4+6=10
- (e) Discuss the types of semiconductorsemiconductor heterojunctions with energy band diagrams. Draw the energy band diagrams before and after junction of the following given specifications of the semiconductors S₁ (p-type), and S₂(n-type) and discuss under forward and reverse bias condition.

$$\phi_{m1} > \phi_{m2}$$

$$E_{g1} < E_{g2}$$

$$\chi_1 > \chi_2$$

$$\gamma_1 < \gamma_2$$